

## SIDC07D60F6

### Fast switching diode

#### Features:

- 600V Emitter Controlled technology 70 μm chip
- soft , fast switching
- low reverse recovery charge
- small temperature coefficient

#### This chip is used for:

 power modules and discrete devices



#### Applications:

• SMPS, resonant applications, drives

Chip Type	$V_{R}$	I <sub>F</sub>	Die Size	Package
SIDC07D60F6	600V	22.5A	2.12 x 3.41 mm <sup>2</sup>	sawn on foil

#### **Mechanical Parameters**

Anode pad size       1.638 x 2.928         Thickness       70       μm         Wafer size       150       mm         Max. possible chips per wafer       2000         Passivation frontside       Photoimide         Pad metal       3200 nm AlSiCu         Backside metal       Ni Ag −system suitable for epoxy and soft solder die bonding         Die bond       Electrically conductive glue or solder         Wire bond       Al, ≤250μm         Reject ink dot size       Ø 0.65mm; max 1.2mm         Store in original container, in dry nitrogen, in dark	Weenamean anameters			
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Reject ink dot size Ø 0.65mm; max 1.2mm  Store in original container, in dry nitrogen, in dark	Die bond	Electrically conductive glue or solder		
Recommended storage environment  Store in original container, in dry nitrogen, in dark	Wire bond	Al, ≤250μm		
	Reject ink dot size	Ø 0.65mm; max 1.2mm		
environment, so menti at an ambient temperature of 20	Recommended storage environment	Store in original container, in dry nitrogen, in dark environment, < 6 month at an ambient temperature of 23°C		



# SIDC07D60F6

#### **Maximum Ratings**

Parameter	Symbol	Condition	Value	Unit	
Repetitive peak reverse voltage	$V_{RRM}$	<i>T</i> <sub>vj</sub> = 25 °C	600	V	
Continuous forward current	I <sub>F</sub>	<i>T</i> <sub>vj</sub> < 150°C	1)	Α	
Maximum repetitive forward current	I <sub>FRM</sub>	<i>T</i> <sub>vj</sub> < 150°C	45	7 ^	
Junction temperature range	$T_{vj}$		-40+175	°C	
Operating junction temperature	T <sub>vj</sub>		-40+150	°C	
Dynamic ruggedness <sup>2)</sup>	P <sub>max</sub>	$I_{\text{Fmax}} = 45\text{A}, \ V_{\text{Rmax}} = 600\text{V}, \ T_{\text{vj}} \le 150^{\circ}\text{C}$	tbd	kW	

<sup>1)</sup> depending on thermal properties of assembly

#### **Static Characteristic** (tested on wafer), $T_{vj}$ = 25 °C

Parameter	Symbol	Conditions	Value			Unit
raiaillelei			min.	typ.	max.	Offic
Reverse leakage current	$I_{R}$	V <sub>R</sub> =600V			27	μA
Cathode-Anode breakdown Voltage	$V_{BR}$	I <sub>R</sub> =1.5mA	600			V
Diode forward voltage	V <sub>F</sub>	I <sub>F</sub> =22.5A		1.6		V

#### **Further Electrical Characteristics**

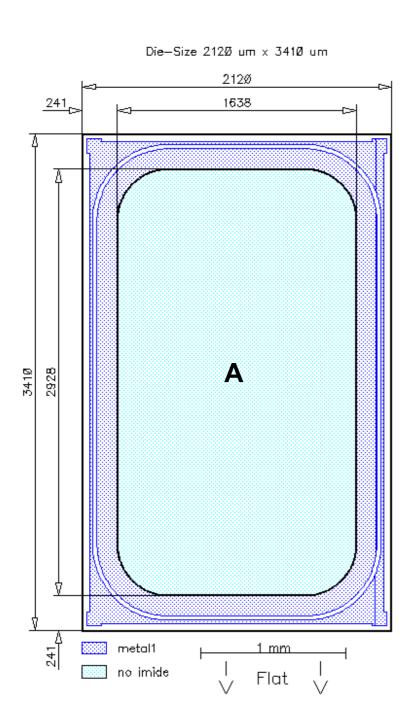
Switching characteristics and thermal properties are depending strongly on module design and mounting technology and can therefore not be specified for a bare die.

<sup>&</sup>lt;sup>2)</sup> not subject to production test - verified by design/characterisation





### **Chip Drawing**



## A: Anode pad



## SIDC07D60F6

Description
AQL 0,65 for visual inspection according to failure catalogue
Electrostatic Discharge Sensitive Device according to MIL-STD 883

#### **Revision History**

Version	Subjects (major changes since last revision)	Date

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